

INTRODUCTION TO Semiconductor Module



Introduction to the Semiconductor Module

© 1998-2017 COMSOL

Protected by U.S. Patents listed on www.comsol.com/patents, and U.S. Patents 7,519,518; 7,596,474; 7,623,991; 8,457,932; 8,954,302; 9,098,106; 9,146,652; 9,323,503; 9,372,673; and 9,454,625. Patents pending.

This Documentation and the Programs described herein are furnished under the COMSOL Software License Agreement (www.comsol.com/comsol-license-agreement) and may be used or copied only under the terms of the license agreement.

COMSOL, the COMSOL logo, COMSOL Multiphysics, Capture the Concept, COMSOL Desktop, LiveLink, and COMSOL Server are either registered trademarks or trademarks of COMSOL AB. All other trademarks are the property of their respective owners, and COMSOL AB and its subsidiaries and products are not affiliated with, endorsed by, sponsored by, or supported by those trademark owners. For a list of such trademark owners, see www.comsol.com/trademarks.

Version: COMSOL 5.3

Contact Information

Visit www.comsol.com/contact for a searchable list of all COMSOL offices and local representatives. From this web page, search the contacts and find a local sales representative, go to other COMSOL websites, request information and pricing, submit technical support queries, subscribe to the monthly eNews email newsletter, and much more.

If you need to contact Technical Support, an online request form is located at www.comsol.com/support/contact.

Other useful links include:

- Technical Support: www.comsol.com/support
- Product downloads: www.comsol.com/support/download
- Software Updates: www.comsol.com/support/updates
- Online Community: www.comsol.com/community
- Events, conferences, and training: www.comsol.com/events
- Tutorials: www.comsol.com/video
- Knowledge Base: www.comsol.com/support/knowledgebase

Part number, CM024103

Contents

Introduction
Semiconductor Devices7
The Semiconductor Module Physics Interface Guide I I
Physics Interface Guide by Space Dimension and Preset Study Type
Tutorial Example: DC Characteristics of a MOSFET16

Introduction

Device engineers and physicists use the Semiconductor Module to design and understand semiconductor devices. For many years semiconductor device design has been closely associated with the use of simulation tools due to the high cost of prototyping new devices and processes. Multiphysics effects often play an important role in semiconductor devices and COMSOL is the ideal platform on which to investigate these effects.

The Semiconductor Module enables the stationary and dynamic performance of devices to be modeled in one, two and three dimensions, together with circuit-based modeling of active and passive devices. In the frequency domain, it is possible to model devices driven by a combination of AC and DC signals. A predefined Semiconductor interface can be used to model a broad range of semiconductor devices and can be straightforwardly coupled with other physics interfaces to model phenomena such as heat generation and optoelectronic effects. A predefined Schrödinger Equation interface allows the modeling of quantum-confined systems such as quantum wells, wires, and dots.

The Semiconductor interface solves the Semiconductor equations by either the finite volume or the finite element method. The physics interface solves a set of coupled partial differential equations for the electric potential and for the electron and hole concentrations (or their logarithm in the case of the finite element method log formulation). The corresponding initial and boundary conditions are easily specified in the physics interface. COMSOL's design emphasizes the physics by providing users with the equations solved by each feature and by offering full access to the underlying equation system. The Semiconductor Module User's Guide provides complete information on the theory underlying the Semiconductor interface. There is also tremendous flexibility to add user-defined equations and expressions to the system. For example user-defined mobility models can be readily specified simply by typing appropriate expressions into the user defined feature, no scripting or coding is required. These user-defined models can be combined arbitrarily with the predefined models built into the software. When COMSOL Multiphysics compiles the equations the complex couplings generated by these user-defined expressions are automatically included in the equation system. The equations are then solved using a range of state of the art solvers. Once a solution is obtained a large range of postprocessing tools are available to interrogate the data, and predefined plots are automatically generated to show the device response. COMSOL Multiphysics offers the flexibility to evaluate a wide range of physical quantities including predefined quantities such as the electron and hole currents (including current components from drift, diffusion and thermal diffusion), the electric field and the temperature (available through easy-to-use menus), as well as arbitrary user-defined expressions.

To model a Semiconductor device the geometry is first defined in the software. Then appropriate materials are selected and the Semiconductor interface is added. The dopant distribution can be computed separately using a diffusion equation calculation, imported from third party software or specified empirically using the built in doping features. Initial conditions and boundary conditions are set up within the physics interface. Next, the mesh is defined and a solver is selected. Finally the results are visualized using a wide range of postprocessing tools. All of these steps are accessed from the COMSOL Desktop graphical user interface.

The Schrödinger Equation interface solves the Schrödinger equation for the wave function of a single particle in an external potential. This can be applied to general quantum mechanical problems, as well as for the electron and hole wave functions in quantum-confined systems under the envelope function approximation. Appropriate boundary conditions and study types are implemented for the user to easily set up models to compute relevant quantities in various situations, such as the eigenenergies of bound states, the decay rates of quasi bound states, the transmission and reflection coefficients, the resonant tunneling condition, and the effective band gap of a superlattice structure. The Double Barrier 1D model and the Superlattice Band Gap Tool app in the Application Libraries illustrate the usage of the various built-in functionalities.

Semiconductor Devices

The semiconductor module can be applied to solve a range of device simulation problems. The Semiconductor interface can be straightforwardly coupled with a range of other physics interfaces, such as the Electromagnetic waves interfaces (using the predefined Semiconductor Optoelectronics multiphysics coupling), the Heat Transfer in Solids interface and the Electrical Circuits interface. Coupling to a circuit is straightforward using the terminals included with all the boundary conditions. Figure 1 shows results obtained from a 2D pn junction model in which a device model of a diode is coupled to an electrical circuit to produce a rectifier. The electron and hole concentrations are shown in the device when different voltages are applied to the circuit.

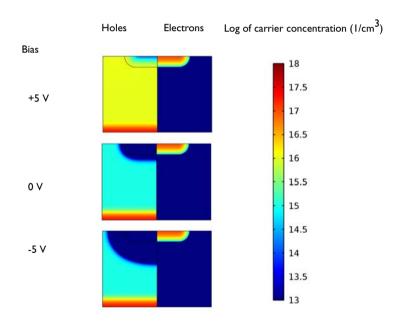


Figure 1: Electron and hole concentrations in a pn-junction diode connected to a series resistor under different bias conditions. This plot shows clearly the changing geometry and extent of the depletion region under reverse bias.

A range of common device types can be simulated with the module, including MOSFETs, MESFETS, JFETS, diodes and Bipolar Transistors. These devices can be analyzed for the stationary case, in the time domain or in the frequency domain, with mixed DC and AC signals, using the small signal analysis study type. A range

of standard analyses are illustrated with the MOSFET model series. The first model in the MOSFET series is described in the section Tutorial Example: DC Characteristics of a MOSFET, below. Figure 2 shows some of the results obtained from this analysis.

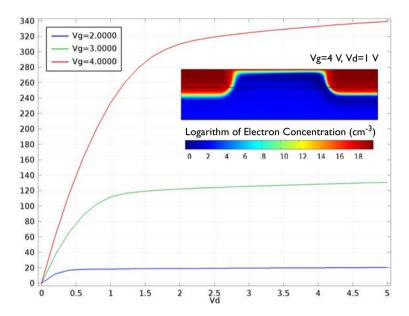


Figure 2: Stationary analysis of a MOSFET. The plot shows the drain current plotted against the drain voltage (V_n) for a range of different values of the gate voltage (V_n) The inset shows the logarithm of the electron concentration (in units of cm⁻³) for a gate voltage of 4 V and for a drain voltage of 1 V. The channel is clearly visible.

In addition to the MOSFET model series, which shows how to include a range of increasingly complicated semiconductor physics effects using features included within the Semiconductor interface, a wide array of other example models are available. The Bipolar Transistor model sequence gives an example of how to set up a multiphysics device simulation. Initially, a model of a 2D cross section of a bipolar transistor device is created using only the Semiconductor interface. This model is then extended by the two other models in the sequence, one adds coupling to the Heat Transfer interface and the other demonstrates how to create a full 3D simulation of the same device. Several individual models are also provided, including a MESFET, an EEPROM device, and some LED models. Figure 3 shows the electron and hole currents flowing in a simple 2D Bipolar transistor.

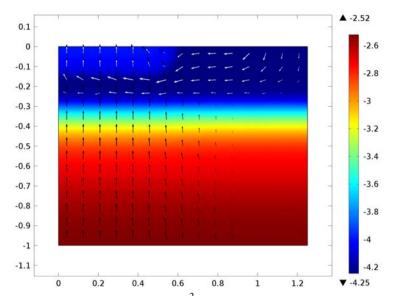
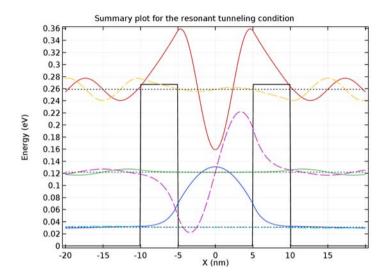


Figure 3: Log of the current density in A/cm^2 (color) and direction of the current flow for electrons (black arrows) and holes (white arrows) in a simple 2D bipolar transistor.

The Semiconductor interface includes a wide range of predefined variables that can be used to access various current components, such as the electron and hole currents as well as the individual contributions to the current from the mobility/electric field, from diffusion and from thermal diffusion.

The Schrödinger Equation interface enables the modeling of various quantum-confined systems. The following graph shows the wave functions shifted by the respective energy levels for the resonant tunneling conditions of a double barrier structure.



The Semiconductor Module Physics Interface Guide

Each COMSOL physics interface (for example the Semiconductor interface, or the Schrödinger Equation interface) expresses the relevant physical phenomena in the form of sets of partial or ordinary differential equations, together with appropriate boundary and initial conditions. Each feature added to the physics interface represents a term or condition in the underlying equation set. These features are usually associated with a geometric entity within the model, such as a domain, boundary, edge (for 3D components), or point. Figure 4 uses the MOSFET application library example to show the Model Builder and the Settings window for the selected Semiconductor Material Model 1 feature node. This node adds the semiconductor equations to the simulation within the domains selected. In the Model Inputs section the temperature of the material is specified. It is straightforward to link this temperature to a separate Heat Transfer interface to solve non-isothermal problems—the Semiconductor interface automatically defines an appropriate heat source term that can be readily accessed in a Heat Transfer interface. In the Material Properties section the Settings window indicate that the relative permittivity and the band gap are inherited from the material properties assigned to the domain. The material properties can be set up as functions of other dependent variables in the model, for example, the temperature. The dopant density is specified by means of multiple additive doping features, which can be used to combine Gaussian and user defined dopant density profiles to produce the desired profile. Several boundary conditions are also indicated in the model tree. The Ohmic Contact boundary condition is commonly used to model non-rectifying interconnects. The Thin Insulating Gate feature models a gate with a thickness smaller than the typical length scale of the mesh. It is also possible to model gates explicitly, solving Poisson's equation within the dielectric.

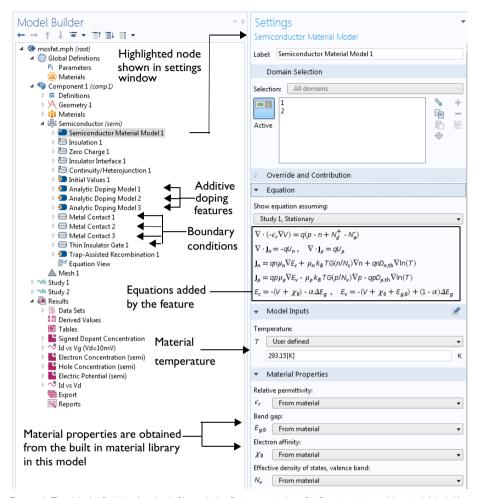


Figure 4: The Model Builder (to the left), and the Settings window for Semiconductor Material Model I for the selected feature node (to the right). The Equation section in the Settings window shows the model equations.

The Semiconductor interface is the starting point for most simulations. The Semiconductor Module also includes physics interfaces to enable modeling of different physical situations encountered in device design. When a new model is started, these physics interfaces are selected from the Model Wizard.

Figure 5 shows the physics interfaces included with the Semiconductor Module. The two Semiconductor Optoelectronics interfaces are only available with an additional Wave Optics module license.

```
      ▲ Semiconductor

      ★ Semiconductor (semi)

      ★ Schrödinger Equation (schr)

      ★ Semiconductor Optoelectronics, Beam Envelopes

      ★ Semiconductor Optoelectronics, Frequency Domain
```

Figure 5: The Semiconductor Module interfaces as displayed in the Model Wizard for a 3D model. The Semiconductor Optoelectronics interfaces are only available with an additional Wave Optics Module license

Also see Physics Interface Guide by Space Dimension and Preset Study Type. Below, a brief overview of each of the Semiconductor Module physics interfaces is given.

ELECTROSTATICS

The Electrostatics interface (), found under the AC/DC branch in the Model Wizard, solves for the electric potential given the charge distribution in the domain and the voltages applied to boundaries. It is used to model electrostatic devices under static or quasi-static conditions, that is at frequencies sufficiently low that wave propagation effects can be neglected. Many of the features of the Electrostatics interface are included in the Semiconductor interface, where they affect the solution of the electric potential.

ELECTRICAL CIRCUIT

The Electrical Circuit interface (), found under the AC/DC branch in the Model Wizard, has the equations to model electrical circuits with or without connections to a distributed fields model. The interface solves for the voltages, currents, and charges associated with the circuit elements. Circuit models can contain passive elements like resistors, capacitors, and inductors as well as active elements such as diodes and transistors. Circuits can be imported from an existing SPICE net list. A typical application of this interface would be to consider the effect of series or parallel lumped components on device behavior.

SEMICONDUCTOR

The Semiconductor interface (ﷺ), found under the Semiconductor branch in the Model Wizard, solves the Semiconductor equations including the equations of electrostatics. The physics interface allows both insulating and semiconducting domains to be modeled. The equations account fully for thermal effects, and the interface can be coupled to a heat transfer interface using the temperature model input and the predefined heat source term. This physics interface is appropriate for modeling semiconductor devices.

SEMICONDUCTOR OPTOELECTRONICS, BEAM ENVELOPES

The interface is used for modeling devices such as photodiodes, light emitting diodes and bulk lasers in direct band gap materials.

SEMICONDUCTOR OPTOELECTRONICS, FREQUENCY DOMAIN

The Semiconductor Optoelectronics, Frequency Domain () interface combines the Semiconductor interface with the Electromagnetic Waves, Frequency Domain interface. The coupling occurs through the Optical Transitions feature, which adds a stimulated emission generation term (appropriate for direct band-gap materials) on domains in the Semiconductor interface. This term is proportional to the optical intensity in the corresponding Wave Equation, Electric feature in the Electromagnetic Waves, Frequency Domain interface. Additionally spontaneous emission (for direct band-gap materials) is accounted for. The effect of the light adsorption or emission is accounted for by a corresponding change in the complex permittivity or refractive index in the Wave Equation, Electric feature.

The interface is used for modeling devices such as photodiodes, light emitting diodes and bulk lasers in direct band gap materials.

SCHRÖDINGER EQUATION

The Schrödinger Equation interface (), found under the Semiconductor branch in the Model Wizard, solves the Schrödinger equation for a single particle in an external potential. This physics interface is useful for general quantum mechanical problems as well as for quantum confined systems such as quantum wells, wires, and dots.

Physics Interface Guide by Space Dimension and Preset Study Type The table below lists the physics interfaces available specifically with this module in addition to the COMSOL Multiphysics basic license.

PHYSICS INTERFACE	ICON	TAG	SPACE DIMENSION	AVAILABLE PRESET STUDY TYPE
₹ AC/DC	·	·		
Electrical Circuit	-	cir	Not space dependent	stationary; frequency domain; time dependent; small signal analysis, frequency domain
Electrostatics ¹	*	es	all dimensions	stationary; time dependent; stationary source sweep; eigenfrequency; frequency domain; small signal analysis, frequency domain
Semiconductor				
Semiconductor	P P	semi	all dimensions	
Semiconductor	N	Seilii	all dimensions	small-signal analysis, frequency domain; stationary; time dependent
Semiconductor Optoelectronics, Beam	A		3D, 2D, and 2D axisymmetric	frequency domain;
Semiconductor Optoelectronics, Beam Envelopes ² Semiconductor Optoelectronics, Frequency Domain ²	N .	——————————————————————————————————————	3D, 2D, and 2D	frequency domain; stationary; time dependent frequency-stationary; frequency-transient; small-signal analysis,

functionality for this module.

 $[\]overset{'}{2}$ Requires both the Wave Optics Module and the Semiconductor Module.

Tutorial Example: DC Characteristics of a MOSFET

This tutorial calculates the DC characteristics of a MOS (metal-oxide semiconductor) transistor. The MOSFET (metal oxide semiconductor field-effect transistor) is by far the most common semiconductor device, and the primary building block in all commercial processors, memories, and digital integrated circuits. Since the first microprocessors were introduced approximately 40 years ago this device has experienced tremendous development, and today it is being manufactured with feature sizes of 22 nm and smaller.

The MOSFET is essentially a miniaturized switch. In this example the source and drain contacts (the input and output of the switch) are both Ohmic (low resistance) contacts to heavily doped n-type regions of the device. Between these two contacts is a region of p-type semiconductor. The gate contact lies above the p-type semiconductor, slightly overlapping the two n-type regions. It is separated from the semiconductor by a thin layer of Silicon oxide, so that it forms a capacitor with the underlying semiconductor. Applying a voltage to the gate changes the local band structure beneath it through the Field Effect. A sufficiently high voltage can cause the semiconductor to change from p-type to n-type in a thin layer (the channel) underneath the gate. This is known as inversion and the channel is sometimes referred to as the inversion layer. The channel connects the two n-type regions of semiconductor with a thin n-type region under the gate. This region has a significantly lower resistance than the series resistance of the np/pn junctions that separated the source and the drain before the gate voltage produced the inversion layer. Consequently applying a gate voltage can be used to change the resistance of the device. The gate voltage where a significant current begins to flow is called the threshold or turn-on voltage. Figure 6 shows a schematic MOSFET with the main electrical connections highlighted. Figure 7 shows an electron microscope image of a modern MOSFET device.

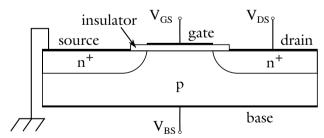


Figure 6: Schematic diagram of a typical MOSFET. The current flows from the source to the drain through a channel underneath the gate. The size of the channel is controlled by the gate voltage.

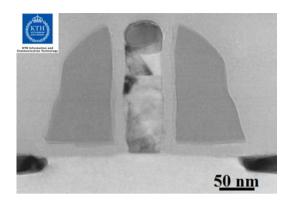


Figure 7: Cross-section TEM (transmission electron microscopy) image of a 50 nm gate length MOSFET fabricated at KTH Electrum laboratory by P.E. Hellström and co-workers within the ERC advanced grant OSIRIS research project headed by Prof. M. Östling.

As the voltage between the drain and the source is increased the current carried by the channel eventually saturates through a process known as pinch-off, in which the channel narrows at one end due to the effect of the field parallel to the surface. The channel width is controlled by the gate voltage. Typically a larger gate voltage results in wider channel and consequently a lower resistance for a given drain voltage. Additionally the saturation current is larger for a higher gate voltage.

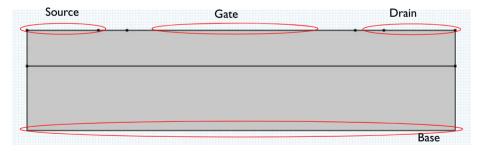


Figure 8: Model geometry showing the external connections.

Figure 8 shows the model geometry, indicating how the geometry elements correspond to features in Figure 6. In this model both the source and the base are connected to ground and the voltages applied to the drain and the gate are varied. In the first study a small voltage (50 mV) is applied to the Drain and the Gate voltage is swept from 0 to 5 V. A plot of the current flowing between the source and the drain is used to determine the turn-on voltage of the device. The second study sweeps the drain voltage from 0 to 5 V at three different values of the gate

voltage (2, 3 and 4 V). The drain current vs. drain voltage is then plotted at several values of the gate voltage.

Model Wizard

Note: These instructions are for the user interface on Windows but apply, with minor differences, also to Linux and Mac.

I To start the software, double-click the COMSOL icon on the desktop. When the software opens, you can choose to use the Model Wizard to create a new COMSOL model or Blank Model to create one manually. For this tutorial, click the Model Wizard button.

If COMSOL is already open, you can start the Model Wizard by selecting New from the File menu and then click Model Wizard .

The Model Wizard guides you through the first steps of setting up a model. The next window lets you select the dimension of the modeling space.

- 2 In the Space Dimension window, click the 2D button .
- 3 In the Select physics tree under Semiconductor, click Semiconductor (semi) 📇 .
- 4 Click Add. Click the Study button 🖨.
- 5 In the tree under Preset Studies, click Stationary 🔁 .
- 6 Click Done **☑**.

Global Definitions

Parameters

On the Home toolbar click Parameters Pi.

Note: On Linux and Mac, the Home toolbar refers to the specific set of controls near the top of the Desktop.

2 In the Settings window locate the Parameters section. In the table, enter the following settings:

NAME	EXPRESSION	DESCRIPTION
Vd	10[mV]	Drain Voltage
Vg	2[V]	Gate Voltage

Geometry I

The geometry can be specified using COMSOL's built in tools. First choose to define geometry objects using micrometer units.

- In the Model Builder under Component 1 click Geometry 1 \n .
- 2 In the Settings window for Geometry locate the Units section. From the Length unit list, choose μm.

Rectangle I

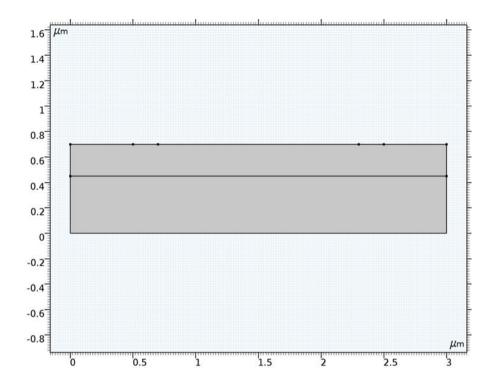
Next create a rectangle to define the geometry extents.

- In the Model Builder, right click Geometry 1 \(\frac{\text{\Lambda}}{\text{and choose Rectangle}}\) □.
- 2 In the Settings window for Rectangle locate the Size section. In the Width text field, type 3. In the Height text field, type 0.7.

Polygon I

Add a polygon that includes points to define the source, drain and gate contacts.

- I Right click Geometry 1 \(\text{\Lambda} \) and choose Polygon \(\text{\text{\Lambda}} \).
- **2** In the Settings window for Polygon locate the Object Type section. From the Type list, choose Closed curve.
- 3 Locate the Coordinates section.
 - In the x text field, type 0 0 0.5 0.7 2.3 2.5 3 3.
 - In the y text field, type 0.45 0.7 0.7 0.7 0.7 0.7 0.45.
- 4 Click the Build All Objects button .



Materials

Add Material

Next the material properties are added to the model.

- I On the Home toolbar click Add Material :
- 2 Go to the Add Material window. In the tree under Semiconductors, click Si 🚦 .
- **3** Click **→** Add to Component.

Semiconductor

Next the physics settings must be defined. Start by defining the carrier statistics and doping.

In the Model Builder click Semiconductor 🚞.

2 In the Settings window for Semiconductor locate the Model Properties section. From the Carrier statistics list, choose Fermi-Dirac.

Analytic Doping Model 1

First a constant background acceptor concentration is defined.

- On the Physics toolbar click the Domains menu and choose Analytic Doping Model .
- 2 In the Settings window for Semiconductor Doping Model locate the Domain Selection section. From the Selection list, choose All domains.
- 3 Locate the Impurity section.
 - From the Impurity type list, choose Acceptor doping (p-type).
 - In the N_{A0} text field, type 1e17[1/cm³].

Analytic Doping Model 2

Add a second doping feature to define the implanted doping profile for the source.

- On the Physics toolbar click the Domains menu and choose Analytic Doping Model .
- 2 In the Settings window for Analytic Doping Model locate the Domain Selection section. From the Selection list, choose All domains.
- **3** Locate the Distribution section. From the list, choose Box.

When defining a Gaussian doping distribution a rectangular region of constant doping is defined. The Gaussian drop off occurs away from the edges of this rectangular region.

Define the location of the lower left corner of the uniformly doped region.

- Locate the Uniform Region section.
 - Specify the r_0 vector as

0[um]	×
0.6[um]	Υ

- 2 Then define the width and height of the uniformly doped region.
 - In the W text field, type 0.6[um].
 - In the D text field, type 0.1[um].

Choose the dopant type and the doping level in the uniformly doped region.

- **3** Locate the Impurity section.
 - From the Impurity type list, choose Donor doping (n-type).
 - In the N_{D0} text field, type 1e20[1/cm³].

Next specify the length scale over which the Gaussian drop off occurs. If doping into a background dopant distribution of opposite type (as in this case), this setting specifies the junction depth. In this model different length scales are used in the x and y directions.

- 4 Locate the Profile section. Select the Specify different length scales for each direction check box.
- 5 Specify the d_i vector as

0.2[um]	X
0.25[um]	Υ

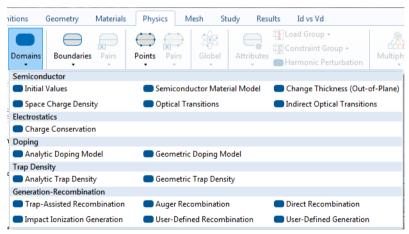
Finally specify the constant background doping level.

6 From the N_b list, choose Acceptor concentration (semi/adm1).

Analytic Doping Model 3

Add a similar Gaussian doping profile for the drain.

On the Physics toolbar click the Domains menu and choose Analytic Doping Model .



- 2 In the Settings window for Analytic Doping Model locate the Domain Selection section. From the Selection list, choose All domains.
- **3** Locate the Distribution section. From the list, choose Box.

- 4 Locate the Uniform Region section.
 - Specify the r_0 vector as

2.4[um]	×
0.6[um]	Υ

- In the *W* text field, type 1.6[um].
- In the *D* text field, type 0.25[um].
- 5 Locate the Impurity section.
 - From the Impurity type list, choose Donor doping (n-type).
 - In the N_{D0} text field, type 1e20[1/cm³].
- 6 Locate the Profile section. Select the Specify different length scales for each direction check box.
 - Specify the d_i vector as

0.2[um]	×
0.25[um]	Υ

7 From the N_b list, choose Acceptor concentration (semi/adm1).

Next set up boundary conditions for the contacts and gate.

Metal Contact 1

First add a contact for the source.

The Metal Contact feature is used to define Metal-Semiconductor interfaces of various types. In this instance use the default Ideal Ohmic contact to define the source.

2 Select Boundary 5 only.

Note: The Metal Contact feature in COMSOL Multiphysics is a terminal boundary condition. By default a fixed potential of 0 V is applied, which is appropriate in this instance, since the source is grounded. The terminal can also be set up to specify a constant current or to connect to an external circuit.

Metal Contact 2

Add a second Metal Contact feature to define the drain.

2 Select Boundary 9 only.

Set the drain voltage to be determined by the previously defined parameter.

3 In the Settings window for Metal Contact locate the Terminal section. In the V_0 text field, type Vd.

Metal Contact 3

Add a third Metal Contact to set the body voltage to 0 V.

- 2 Select Boundary 2 only.

Thin Insulator Gate 1

Set up the Gate. The Gate dielectric is not explicitly represented in the model, instead the Thin Insulator Gate boundary condition represents both the gate contact and the thin layer of oxide.

The Thin Insulator Gate feature is also a terminal, but in this instance it is possible to fix the voltage or charge on the terminal, as well as to connect it to a circuit.

Note: The charge setting determines the charge on the terminal and does not relate to trapped charge at the interface.

The voltage applied to the gate is determined by the parameter previously added.

- 2 In the V_0 text field, type Vg.
- 3 Locate the Gate Contact section.
 - In the ε_{ins} text field, type 4.5.
 - In the d_{ins} text field, type 30[nm].
- 4 Select Boundary 7 only.

Trap-Assisted Recombination I

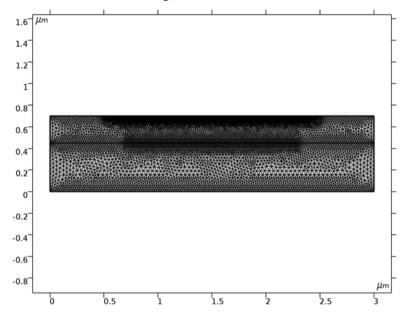
A range of recombination/generation mechanisms are available to be added to the model. In this case we simply add trap-assisted recombination, using the default Shockley-Reed-Hall model.

- On the Physics toolbar click the Domains menu and choose Generation-Recombination>Trap-Assisted Recombination
- 2 In the Settings window for Trap-Assisted Recombination locate the Domain Selection section. From the Selection list, choose All domains.

Mesh I

The physics-based mesh settings can be used for this model.

In the Model Builder right-click Mesh $1 \triangleq$ and choose Build all \blacksquare . The mesh is shown in the image below.



Study I

Before setting up the study, check that the doping was set up correctly. To do this, first get the initial value for the study.

- In the Model Builder click Study 1 ∞.

 Disable the default plots since these are not required.
- **2** In the Settings window for Study locate the Study Settings section. Click to clear the Generate default plots check box.
- 3 On the Study toolbar click Get Initial Value 🛂 .

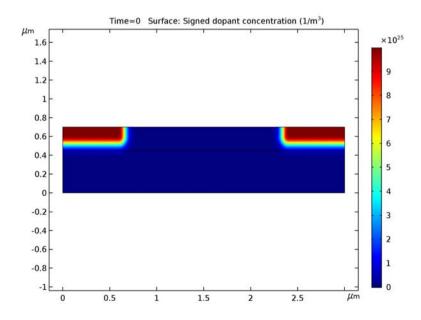
Results

2D Plot Group 1

Add a 2D plot group to check the dopant distribution in the model.

- On the Home toolbar click Add Plot Group and choose 2D Plot Group.
- 2 Rename the Plot Group by typing "Signed Dopant Concentration" in the Label field.
- 3 On the Signed Dopant Concentration toolbar click Surface ...
 Plot the signed dopant concentration (Nd-Na). This quantity is positive for net donor doping and negative for net acceptor doping.
- 4 In the Model Builder under Results>Signed Dopant Concentration, click Surface 1 ...
- 5 In the Settings window for Surface click Replace Expression (it is in the upper-right corner of the y-Axis Data section). In the menu, double-click Model>Component1>Semiconductor>Carriers and dopants>semi.Ndoping-Signed dopant concentration.
- 6 Click the Plot button .

The doping distribution is shown below.



Study I

Step 1: Stationary

Now set up a Stationary study to determine the turn-on voltage for the transistor. In this study we set Vd to 10 mV and sweep over Vg.

- In the Model Builder under Study 1, click Step 1: Stationary 🔁.
- 2 In the Settings window for Stationary click to expand the Study extensions section.

The study extensions panel can be used to set up a parametric sweep.

- **3** Locate the Study Extensions section. Select the Auxiliary sweep check box.
- **4** From the Sweep type list, choose All combinations. This sweeps over every combination of the two parameters.
- **5** Click Add +. In the table, enter the following settings:

PARAMETER NAME	PARAMETER VALUE LIST
Vd	0.01

The drain voltage is fixed at a constant value.

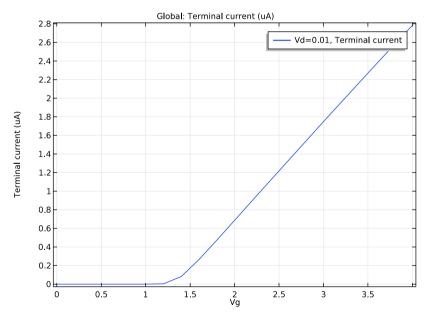
- 6 Click Add +.
- - In the Start text field, type 0.
 - In the Step text field, type 0.2.
 - In the Stop text field, type 4.
- 8 Click the Replace button. The gate voltage is swept between 0 and 4V. By default the Run continuation for setting is set to Last parameter (Vg in this case). This setting configures the solver to use the solution for the previous value of Vg as the initial guess for the solution when solving for the next value of Vg. It also allows the solver to take intermediate steps at values of Vg not specified in the list if necessary.
- **9** From the Reuse solution for previous step list, choose Auto.
- **10** On the Home toolbar click Compute **■** .

ID Plot Group 2

Add a 1D plot group to plot the source current versus the gate voltage.

- I On the Home toolbar click Add Plot Group \blacksquare and choose 1D Plot Group \sim .
- 2 Rename the Plot Group by typing "Id vsVg (Vd=10mV)" in the Label field.
- 3 On the 1D Plot Group toolbar click Global .

 The postprocessing menus contain a wide range of quantities available for plotting. Choose the current flowing out of terminal 1.
- **5** Change the Unit to uA and click the Plot button **a**.



From the plot it is clear that the threshold voltage, V_T , of the transistor is approximately 1.2 V. It is possible to compare this value with the theoretical value given by (S. M. Sze and K. K. Ng, *Physics of Semiconductor Devices*, Wiley, Hoboken, New Jersey, pp. 305–306, 2007):

$$V_{T} \cong V_{FB} + 2\psi_{B} + \frac{d_{ox}(4\varepsilon_{r,s}\varepsilon_{0}qN_{a}\psi_{B})^{\frac{1}{2}}}{\varepsilon_{r,ox}\varepsilon_{0}}$$

where d_{ox} is the thickness of the oxide and $\varepsilon_{r,ox}$ is its relative permittivity, ε_0 is the permittivity of free space, $\varepsilon_{r,s}$ is the relative permittivity of the semiconductor, q is the electron charge and N_a is the acceptor concentration under the gate. The flat band voltage V_{FB} and the potential difference between the intrinsic level and the Fermi-level, Ψ_B , are given by the following equations:

$$\begin{split} V_{FB} &= \Phi_m - \chi + \frac{k_B T}{q} \ln \left(\frac{n_{eq}}{N_c} \right) \\ \psi_B &= \frac{k_B T}{q} \ln \left(\frac{p_{eq}}{n_i} \right) \end{split}$$

where Φ_m is the work function of the metal contact, χ is the semiconductor electron affinity, k_B is Boltzmann's contact, T is the absolute temperature, N_c is the semiconductor density of states in the conduction band and n_i is the intrinsic carrier density. The equilibrium electron (n_{eq}) and hole (p_{eq}) densities are given by:

$$\begin{split} n_{eq} &= \frac{1}{2}(N_d - N_a) + \frac{1}{2}\sqrt{\left(N_d - N_a\right)^2 + 4n_i} \\ p_{eq} &= -\frac{1}{2}(N_d - N_a) \pm \frac{1}{2}\sqrt{\left(N_d - N_a\right)^2 + 4n_i} \end{split}$$

Where N_d is the donor concentration under the gate. Note that these equations assume both complete ionization and Maxwell Boltzmann statistics (reasonable assumptions in the region under the gate). These equations give a threshold voltage of 1.20 V, in good agreement with the simulation value.

Study 2

Now add an additional study to plot the source current as a function of drain voltage at a range of different gate voltages.

- I On the Home toolbar click Add Study [∞].
- 2 In the Add Study window, find the Studies subsection. In the tree under Preset Studies, click Stationary \triangleright .
- **3** Click Add Study + in the window toolbar.
- 4 On the Home toolbar click Add Study 🗠 to close the Add Study window.

Step 1: Stationary

- In the Model Builder under Study 2, click Step 1: Stationary \succeq .
- 2 In the Settings window for Stationary locate the Study Extensions section.
- **3** Select the Auxiliary sweep check box.
- **4** From the Sweep type list choose All combinations. Click Add ★. Select Vg from the Parameter name drop down menu.

Now set up the study to sweep over Vg.

Note: When solving for three values of the gate voltage, this model takes approximately an hour to solve. To save time it is possible to solve only for a single gate voltage. To do this, enter 4 in the Parameter Value List text field and click Compute **=** . Then go to the end of this section.

- - In the Start text field, type 2.
 - In the Step text field, type 1.
 - In the Stop text field, type 4.
- 6 Click Replace.
- 7 In the Settings window for Stationary locate the Study Extensions section. Click Add + . In this case the default Auxiliary Parameter, Vd is the desired parameter for the sweep.
- - In the Start text field, type 0.
 - In the Step text field, type 0.2.
 - In the Stop text field, type 5.
- 9 Click Replace.
- 10 In the Settings window for Stationary locate the Study Extensions section. From the Run continuation for list, choose Manual. Then from the Continuation parameter list, choose Vd.

The continuation solver should use the inner sweep over Vd, since the solution only changes slightly between close values of Vd.

- II From the Reuse solution for previous step list, choose Auto.
- **12** On the Home toolbar click Compute **■** .

Results

The pinch-off of the channel is apparent in the plots of the electron concentration and the potential distribution at Vd values of 0, 1 and 5 V.

Electron Concentration (semi)

- In the Model Builder under Results, click Electron Concentration (semi) ■. By default the plot shows the results for the case Vd=5 V and Vg=4 V.
- 2 In the Settings window for 2D Plot Group locate the Data section. Change the Vd Parameter value to 1 V and then to 0 V, each time selecting the Plot button to see how the results change.

Electric Potential (semi)

- In the Model Builder under Results, click Electric Potential (semi)
- 2 Look at the plot for Vd values of 5 V, 1 V and 0 V.

 The plots in Figure 9 show the results. The pinch off effect is apparent at 5 V.

 Add another 1D plot group to plot the drain current vs the drain voltage.
- 3 On the Home toolbar select Add Plot Group \P , and choose 1D Plot Group \sim .
- 4 Rename the plot group by typing "Id vs Vd" in the Label field.
- 5 In the Settings window for 1D Plot Group locate the Data section. From the Data set list, choose Study 2/Solution 2.

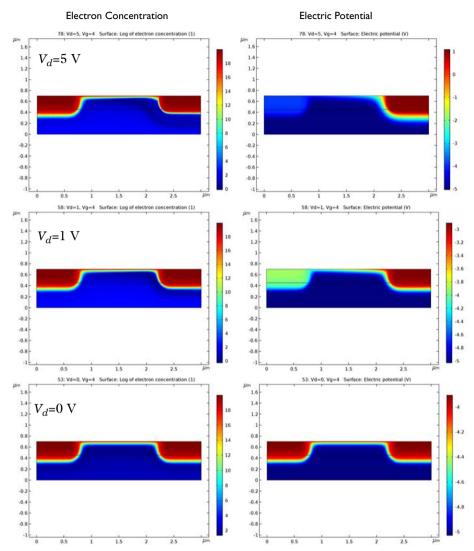
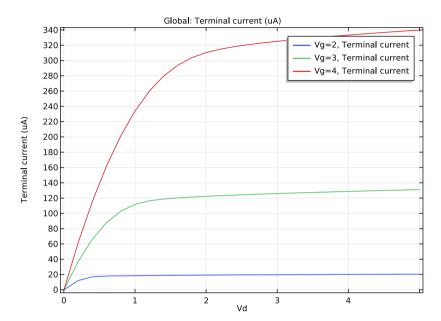


Figure 9: The pinch-off of the channel is apparent in the plots of the electron concentration and the potential distribution at Vd values of 0, $\,$ I and 5 $\,$ V.

ID Plot Group 6

- I From the Id vs Vd toolbar click Global €.
- 2 In the Model Builder under Results>Id vs Vd, click Global 1 €.

- 3 In the Settings window for Global click Replace Expression ▶ in the upper-right corner of the y-Axis Data section. In the menu, double click on Model>Component1>Semiconductor>Terminals>semi.I0_2-Terminal Current.
- 4 Change the Unit to uA for the current.
- **5** Click the Plot button **5** .



The drain current vs drain voltage diagram shows a linear region for low bias, followed by a nonlinear region. The drain current increases slightly with voltage in the saturation region at higher drain voltages, as a result of short channel effects. Short channel effects mean that the standard analytic expressions for the saturation voltage and current do not apply, but the saturation voltages and currents are of a similar magnitude to those predicted by the simple theory (S. M. Sze and K. K. Ng, *Physics of Semiconductor Devices*, Wiley, Hoboken, New Jersey, pp. 305–306, 2007).